

WHAT IS CLAIMED IS:

1 1. A vertical cavity surface emitting laser (VCSEL) operable to generate
2 single-mode laser light at an operative wavelength, comprising:
3 a light-emitting surface; and
4 a monolithic longitudinal stack structure including
5 a first mirror having an optical reflectivity R_1 for light at the
6 operative wavelength,
7 a second mirror having an optical reflectivity R_2 for light at the
8 operative wavelength, wherein R_1 and R_2 have different
9 respective values one of which is greater than 99.9% and
10 another of which is less than 99.7%,
11 a cavity region disposed between the first mirror and the second
12 mirror and including an active light generation region and a
13 cavity extension region;
14 wherein the longitudinal stack structure further includes an ion-implanted
15 current confinement region characterized by a peak longitudinal implant
16 concentration separated from the cavity region by a longitudinal distance greater
17 than 0.5 μm .

1 2. The VCSEL of claim 1, further comprising a metal contact disposed
2 on the light emitting surface and defining an aperture, wherein the ion-implanted
3 current confinement region defines a current aperture larger than the aperture of
4 the metal contact.

1 3. The VCSEL of claim 1, wherein both R_1 and R_2 are at least 99.5%.

1 4. The VCSEL of claim 1, wherein the cavity extension region has a
2 longitudinal optical thickness greater than twice the operative wavelength.

1 5. The VCSEL of claim 1, wherein the longitudinal optical thickness of
2 the cavity extension region is less than about twenty times the operative
3 wavelength.

1 6. The VCSEL of claim 1, wherein each of the first and second mirrors
2 comprises a respective stack of alternating layers of different refractive index
3 materials each having a longitudinal optical thickness substantially equal to one-
4 quarter of the operative wavelength, and the cavity region without the cavity
5 extension region has a longitudinal optical thickness substantially equal to the
6 operative wavelength.

1 7. The VCSEL of claim 6, wherein the cavity extension region is
2 adjacent to one of the alternating layers of the first and second mirrors.

1 8. The VCSEL of claim 1, wherein the cavity extension region has a
2 longitudinal optical thickness substantially equal to an integral multiple of one-
3 half the operative wavelength.

1 9. The VCSEL of claim 1, wherein the cavity extension region is
2 disposed adjacent to the second mirror and has the same composition as one of
3 the different refractive index materials in the second mirror stack.

1 10. The VCSEL of claim 1, wherein the cavity extension region is
2 disposed between the active light generation region and the second mirror.

1 11. The VCSEL of claim 1, wherein a first portion of the cavity
2 extension region is adjacent to the first mirror and second portion of the cavity
3 extension region is adjacent to the second mirror.

1 12. The VCSEL of claim 1, wherein the ion-implanted current
2 confinement region is characterized by a longitudinal straggle and the peak
3 longitudinal implant concentration is separated from the cavity region by a
4 longitudinal distance greater than three times the longitudinal straggle.

1 13. The VCSEL of claim 1, wherein the current confinement region
2 defines a current aperture with a diameter of less than 12 micrometers.

1 14. An array of two or more vertical cavity surface emitting lasers
2 (VCSELs), each VCSEL comprising:
3 a light-emitting surface; and

4 a monolithic longitudinal stack structure including
5 a first mirror having an optical reflectivity R_1 for light at the
6 operative wavelength,
7 a second mirror having an optical reflectivity R_2 for light at the
8 operative wavelength, wherein R_1 and R_2 have different
9 respective values one of which is greater than 99.9% and
10 another of which is less than 99.7%,
11 a cavity region disposed between the first mirror and the second
12 mirror and including an active light generation region and a
13 cavity extension region;
14 wherein the longitudinal stack structure further includes an ion-implanted
15 current confinement region characterized by a peak longitudinal implant
16 concentration separated from the cavity region by a longitudinal distance greater
17 than 0.5 μm .

1 15. A method of manufacturing a vertical cavity surface emitting laser
2 (VCSEL), comprising:
3 forming a light-emitting surface and a monolithic longitudinal stack
4 structure, the monolithic longitudinal stack structure including
5 a first mirror having an optical reflectivity R_1 for light at the
6 operative wavelength,
7 a second mirror having an optical reflectivity R_2 for light at the
8 operative wavelength, wherein R_1 and R_2 have different
9 respective values one of which is greater than 99.9% and
10 another of which is less than 99.7%,
11 a cavity region disposed between the first mirror and the second
12 mirror and including an active light generation region and a
13 cavity extension region;
14 implanting ions in an current confinement region characterized by a peak
15 longitudinal implant concentration separated from the cavity region by a
16 longitudinal distance greater than 0.5 μm .

1 16. The method of claim 15, further comprising forming on the light
2 emitting surface a metal contact defining an aperture, wherein the ion-implanted
3 current confinement region defines a current aperture larger than the aperture of
4 the metal contact.

1 17. The method of claim 15, wherein the cavity extension region has a
2 longitudinal optical thickness greater than twice the operative wavelength and
3 less than about twenty times the operative wavelength.

1 18. The method of claim 15, wherein each of the first and second
2 mirrors comprises a respective stack of alternating layers of different refractive
3 index materials each having a longitudinal optical thickness substantially equal to
4 one-quarter of the operative wavelength, and the cavity region without the cavity
5 extension region has a longitudinal optical thickness substantially equal to the
6 operative wavelength.

1 19. The method of claim 18, wherein the cavity extension region has a
2 longitudinal optical thickness substantially equal to an integral multiple of one-
3 half the operative wavelength.

1 20. The method of claim 18, wherein the cavity extension region is
2 disposed adjacent to the second mirror and has the same composition as one of
3 the different refractive index materials in the second mirror stack.